

<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>		Application No.	10/518,216
		Filing Date	September 26, 2005
		First Named Inventor	Norio Murase
		Art Unit	1793
(Multiple sheets used when necessary)		Examiner	Koslow, Carol M.
SHEET 1 OF 1		Attorney Docket No.	SAEG129.007APC

U.S. PATENT DOCUMENTS					
Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
/M.H./	1	5,866,039 A	02-02-1999	Morton, David C.	
/M.H./	2	5,585,640 A	12-17-1996	Huston, Alan L.	

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T <sup>1</sup>
/M.H./	3	WO 99/50916 A1	10-07-1999	Massachusetts Inst. Technology		

NON PATENT LITERATURE DOCUMENTS						
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.				T <sup>1</sup>
/M.H./	4	KAPITONOV, A.M. et al. (1999) "Luminescence properties of thiol-stabilized CdTe nanocrystals" Journal of Physical Chemistry. B, Materials, Surfaces, Interfaces and Biophysical 103:10109-10113.				
/M.H./	5	ROGACH, A. et al. (2000) "Raisin-bun-type composite spheres of silica and semiconductor nanocrystals" Chemistry of Materials, American Chemical Society 12:2676-2685.				
/M.H./	6	SUPPLEMENTAL EUROPEAN SEARCH REPORT from corresponding European patent application no. EP 03 72 5759.				

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Examiner Signature	/Matthew Hoban/	Date Considered	02/13/2008
<b>*Examiner:</b> Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.			

T<sup>1</sup> - Place a check mark in this area when an English language Translation is attached.